Nov 2005

SemiHow
SEMICONDUCTOR TOTAL SOLUTION®

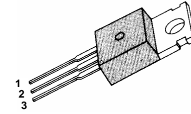
BV_{DSS} = 600 V

$R_{DS(on)\ typ}$ = 0.64 Ω

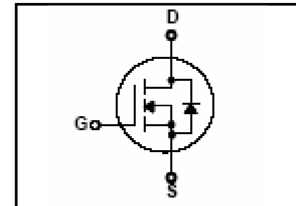
I_D = 9.5 A

HFP10N60
600V N-Channel MOSFET

TO-220



1.Gate 2. Drain 3. Source



FEATURES

- ❑ Originative New Design
- ❑ Superior Avalanche Rugged Technology
- ❑ Robust Gate Oxide Technology
- ❑ Very Low Intrinsic Capacitances
- ❑ Excellent Switching Characteristics
- ❑ Unrivalled Gate Charge : 15 nC (Typ.)
- ❑ Extended Safe Operating Area
- ❑ Lower $R_{DS(ON)}$: 0.64 Ω (Typ.) @V_{GS}=10V

Absolute Maximum Ratings

T_C=25℃ unless otherwise specified

Symbol	Parameter	Value	Units
V_{DSS}	Drain-Source Voltage	600	V
I_D	Drain Current – Continuous (T_C = 25℃)	9.5	A
	Drain Current – Continuous (T_C = 100℃)	6.03	A
I_{DM}	Drain Current – Pulsed (Note 1)	38	A
V_{GS}	Gate-Source Voltage	±30	V
E_{AS}	Single Pulsed Avalanche Energy (Note 2)	520	mJ
I_{AR}	Avalanche Current (Note 1)	9.5	A
E_{AR}	Repetitive Avalanche Energy (Note 1)	15.6	mJ
dv/dt	Peak Diode Recovery dv/dt (Note 3)	5.5	V/ns
P_D	Power Dissipation (T_C = 25℃)	156	W
	– Derate above 25℃	1.25	W/℃
T_J, T_{STG}	Operating and Storage Temperature Range	-55 to +150	℃
T_L	Maximum lead temperature for soldering purposes, 1/8" from case for 5 seconds	300	℃

Thermal Resistance Characteristics

Symbol	Parameter	Typ.	Max.	Units
$R_{\theta JC}$	Junction-to-Case	--	0.8	℃/W
$R_{\theta CS}$	Case-to-Sink	0.5	--	
$R_{\theta JA}$	Junction-to-Ambient	--	62.5	

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Electrical Characteristics T_C=25 °C unless otherwise specified

Symbol	Parameter	Test Conditions	Min	Typ	Max	Units
On Characteristics						
V_{GS}	Gate Threshold Voltage	$V_{DS} = V_{GS}$, I_D = 250 ㎂	2.5	--	4.5	V
$R_{DS(ON)}$	Static Drain-Source On-Resistance	V_{GS} = 10 V, I_D = 4.75 A	--	0.64	0.8	Ω
Off Characteristics						
BV_{DSS}	Drain-Source Breakdown Voltage	V_{GS} = 0 V, I_D = 250 ㎂	600	--	--	V
$\Delta BV_{DSS} / \Delta T_J$	Breakdown Voltage Temperature Coefficient	I_D = 250 ㎂, Referenced to25℃	--	0.65	--	V/℃
I_{DSS}	Zero Gate Voltage Drain Current	V_{DS} = 600 V, V_{GS} = 0 V	--	--	1	㎂
		V_{DS} = 480 V, T_C = 125℃	--	--	10	㎂
I_{GSSF}	Gate-Body Leakage Current, Forward	V_{GS} = 30 V, V_{DS} = 0 V	--	--	100	nA
I_{GSSR}	Gate-Body Leakage Current, Reverse	V_{GS} = -30 V, V_{DS} = 0 V	--	--	-100	nA
Dynamic Characteristics						
C_{iss}	Input Capacitance	V_{DS} = 25 V, V_{GS} = 0 V, f = 1.0 MHz	--	1300	1700	pF
C_{oss}	Output Capacitance		--	110	145	pF
C_{rss}	Reverse Transfer Capacitance		--	23	30	pF
Switching Characteristics						
$t_{d(on)}$	Turn-On Time	V_{DS} = 300 V, I_D = 9.5 A, R_G = 25 Ω (Note 4,5)	--	27	55	ns
t_r	Turn-On Rise Time		--	75	150	ns
$t_{d(off)}$	Turn-Off Delay Time		--	120	240	ns
t_f	Turn-Off Fall Time		--	80	160	ns
Q_g	Total Gate Charge	V_{DS} = 480V, I_D = 9.5 A, V_{GS} = 10 V (Note 4,5)	--	33	43	nC
Q_{gs}	Gate-Source Charge		--	7.3	--	nC
Q_{gd}	Gate-Drain Charge		--	15	--	nC
Source-Drain Diode Maximum Ratings and Characteristics						
I_S	Continuous Source-Drain Diode Forward Current		--	--	9.5	A
I_{SM}	Pulsed Source-Drain Diode Forward Current		--	--	38	A
V_{SD}	Source-Drain Diode Forward Voltage	I_S = 9.5 A, V_{GS} = 0 V	--	--	1.4	V
trr	Reverse Recovery Time	I_S = 9.5 A, V_{GS} = 0 V, di_F/dt = 100 A/μs (Note 4)	--	430	--	ns
Qrr	Reverse Recovery Charge		--	5.8	--	μC

Notes ;

1. Repetitive Rating : Pulse width limited by maximum junction temperature
2. L=10.56mH, I_{AS}=9.5A, V_{DD}=50V, R_G=25Ω, Starting T_J=25°C
3. I_{SD}≤9.5A, di/dt≤300A/μs, V_{DD}≤BV_{DSS} , Starting T_J =25 °C
4. Pulse Test : Pulse Width ≤ 300μs, Duty Cycle ≤ 2%
5. Essentially Independent of Operating Temperature

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Typical Characteristics

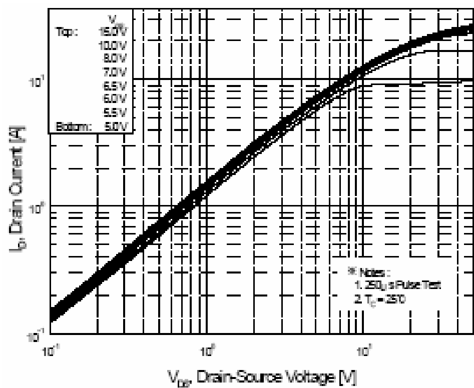

Figure 1. On Region Characteristics

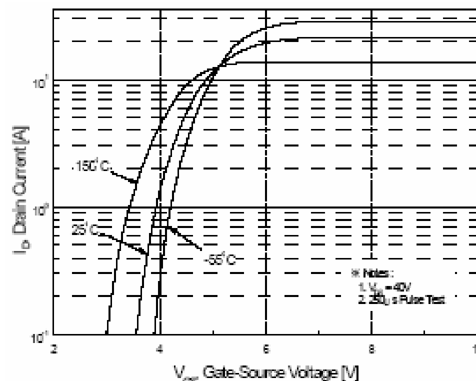

Figure 2. Transfer Characteristics

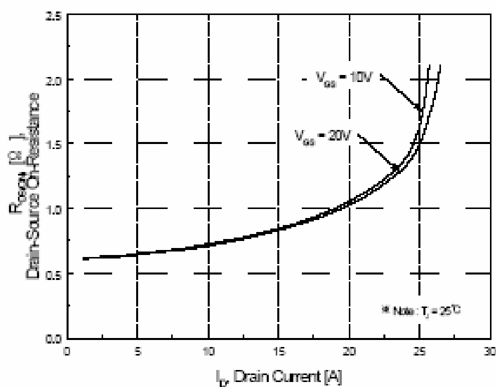

Figure 3. On Resistance Variation vs Drain Current and Gate Voltage

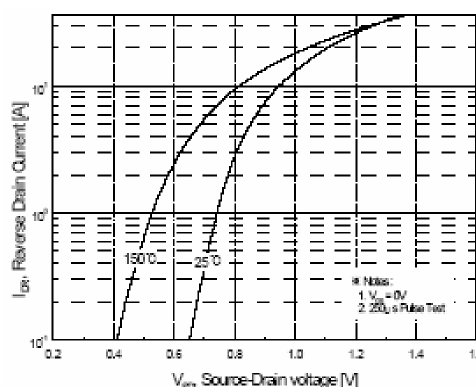

Figure 4. Body Diode Forward Voltage Variation with Source Current and Temperature

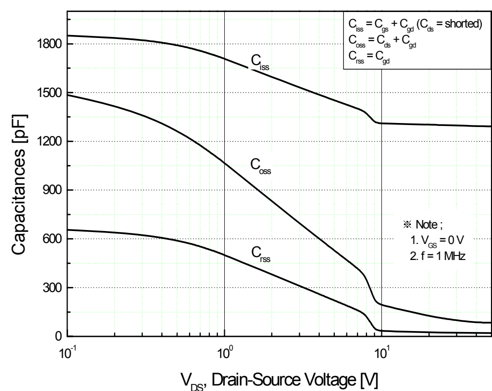

Figure 5. Capacitance Characteristics

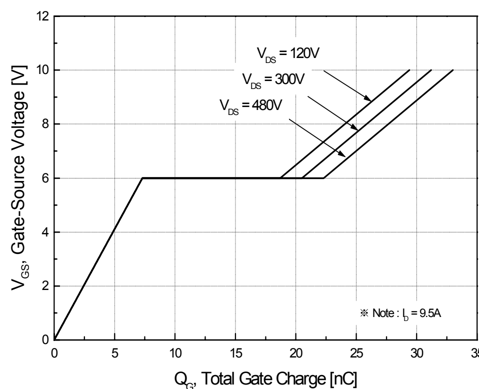

Figure 6. Gate Charge Characteristics

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Typical Characteristics (continued)

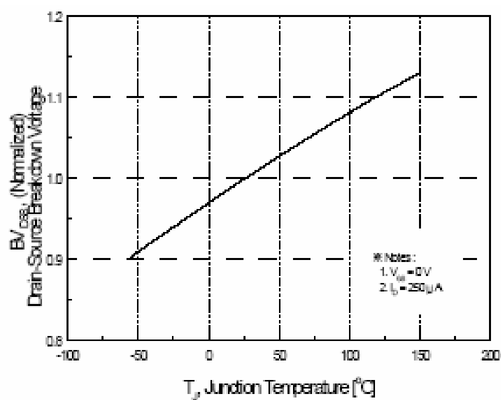

Figure 7. Breakdown Voltage Variation vs Temperature

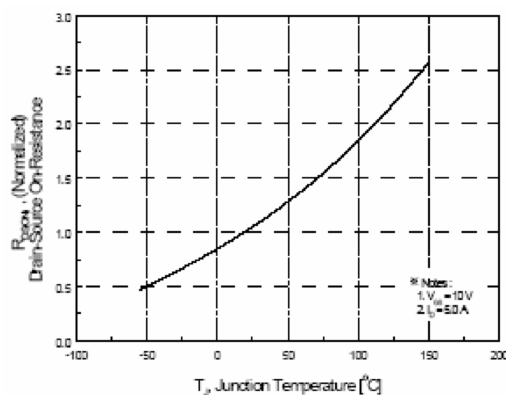

Figure 8. On-Resistance Variation vs Temperature

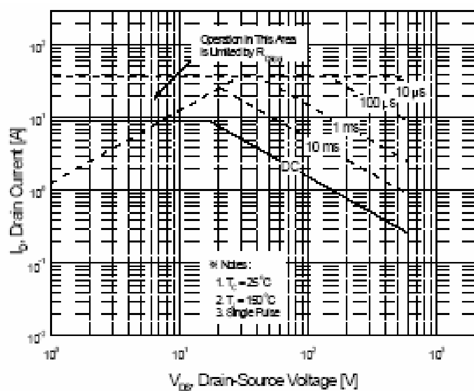

Figure 9. Maximum Safe Operating Area

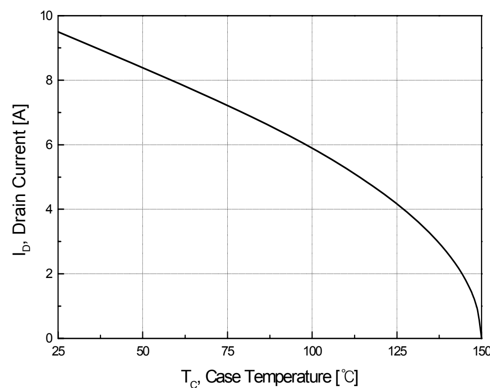

Figure 10. Maximum Drain Current vs Case Temperature

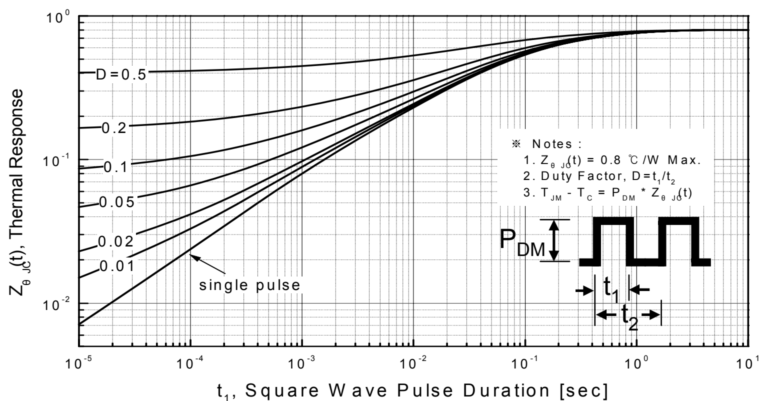

Figure 11. Transient Thermal Response Curve

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Fig 12. Gate Charge Test Circuit & Waveform

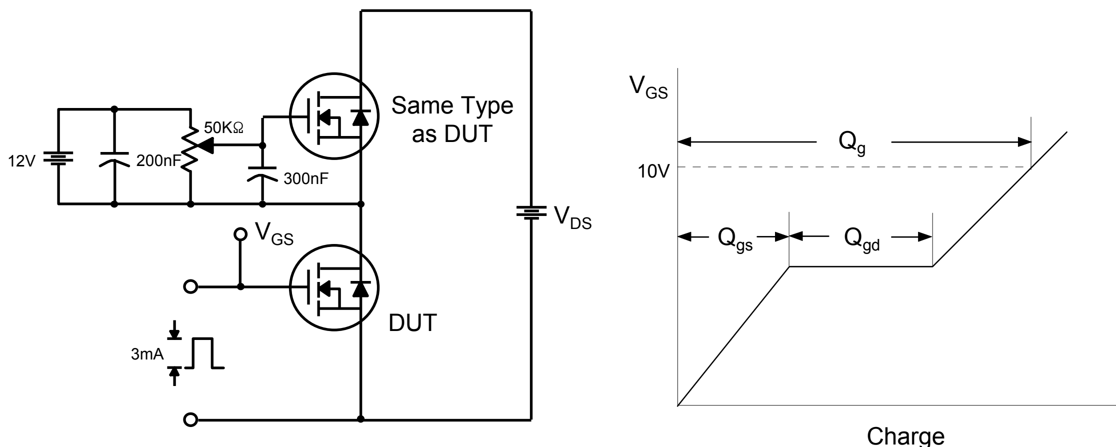

Fig 13. Resistive Switching Test Circuit & Waveforms

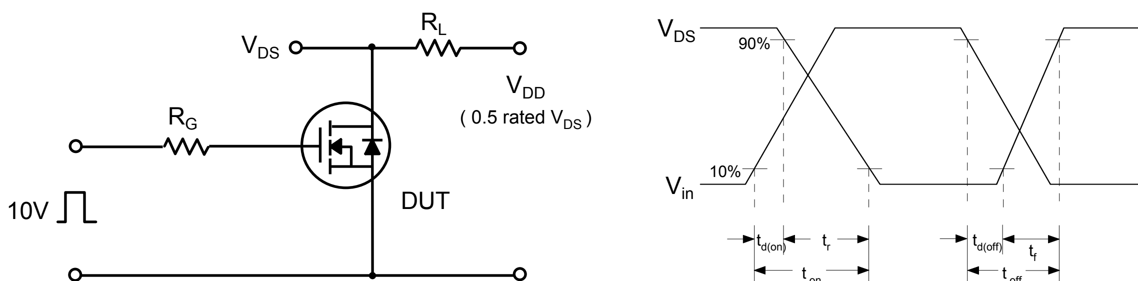

Fig 14. Unclamped Inductive Switching Test Circuit & Waveforms

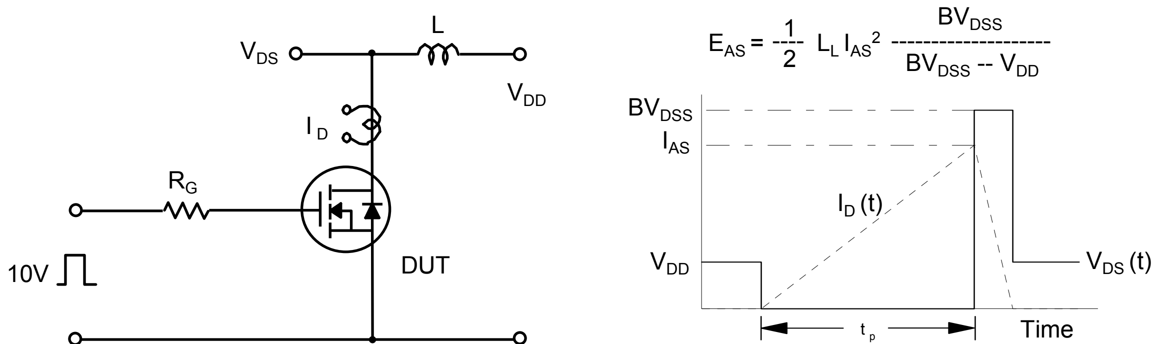

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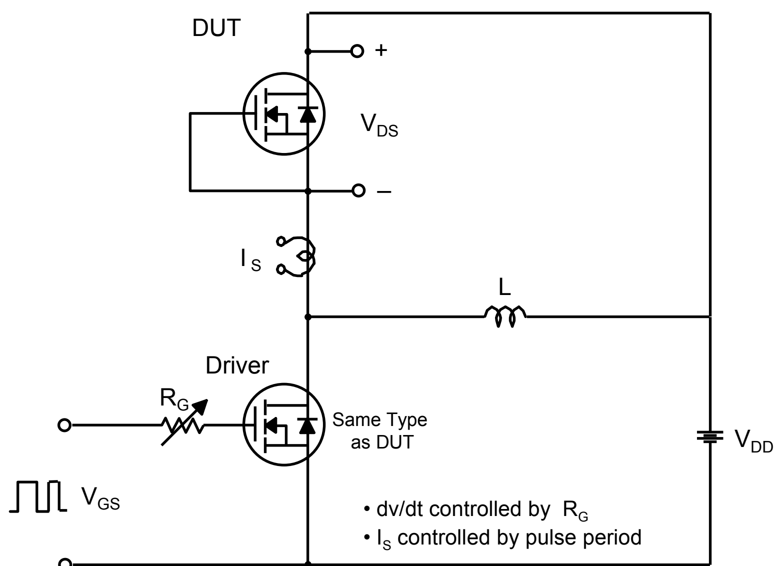
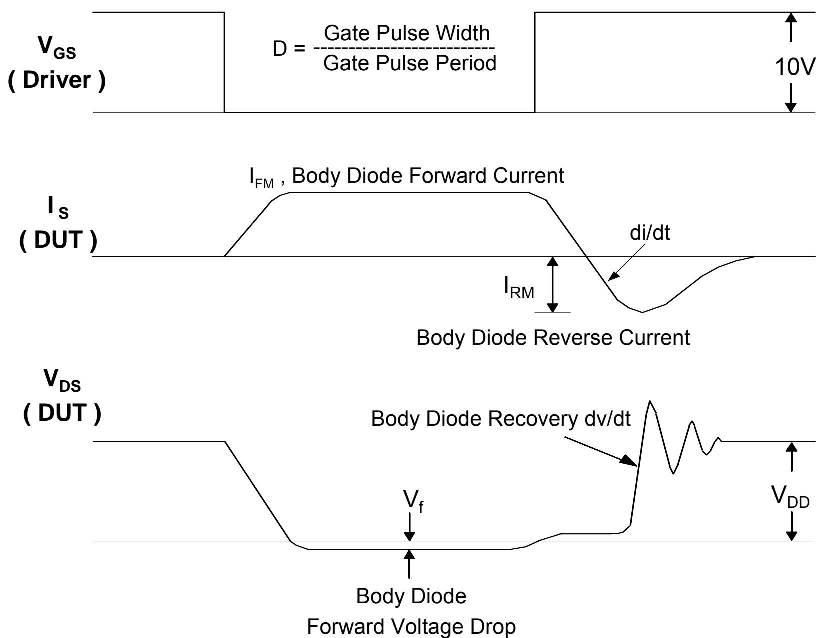
Fig 15. Peak Diode Recovery dv/dt Test Circuit & Waveforms





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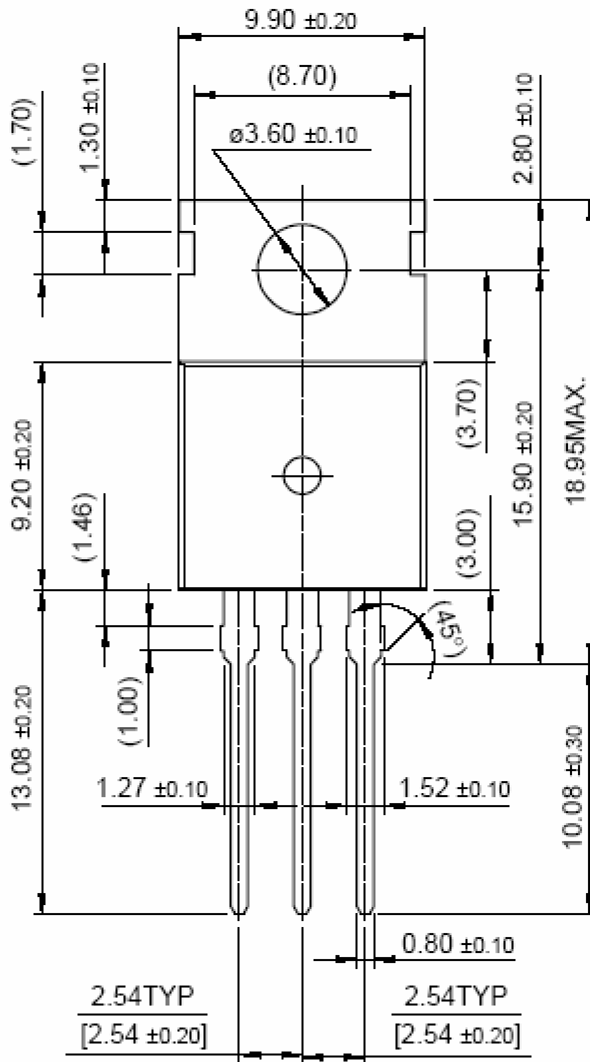
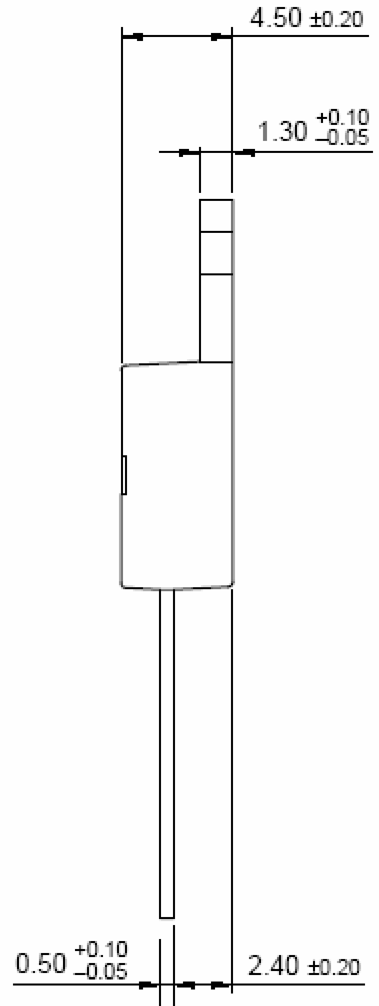
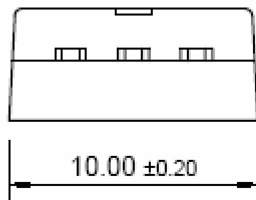
Package Dimension

TO-220







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Reliability Qualification

A. High Temperature Reverse Bias (HTRB)

The purpose of this test is to determine the sensitivity of the product to mobile ion contamination and related failure mechanisms.

Conditions: JESD22-A108, JIS C 7021 B-8

T_A=150℃ V_{DS}=80% max rated V_{DS}

Sample Size	#of Fail	Cum. Fail%	168hrs	300hrs
45	0	0.0%	0	0

B. High Temperature Gate Bias (HTGB)

The purpose of this test is to determine the sensitivity of the product to mobile ion contamination between gate and source and related failure mechanisms.

T_A=150℃ V_{DS}= V_{GSS} max

Sample Size	#of Fail	Cum. Fail%	168hrs	300hrs
45	0	0.0%	0	0

C. Pressure Cooker Test (PCT)
Autoclave (ACLV)

The purpose of this test is to evaluate the moisture resistance of non-hermetic components under pressure/temperature conditions.

Conditions: JESD22-A102, JIS C 7021 A-6

T_A=121℃ RH=100% P=1 atmosphere (15psig)

Sample Size	#of Fail	Cum. Fail%	48hrs
45	0	0.0%	0

Reliability Qualification (Continued)

D. Temperature Humidity Bias (THBT)

The purpose of this test is to evaluate the moisture resistance of non-hermetic components.
The addition of voltage bias accelerates the corrosive effect after moisture penetration has taken place.
with time, this is a catastrophically destructive test.
Conditions: JESD22-A101
T_A=85℃ RH=85% V_{DS}=80% max rated V_{DS}

Sample Size	#of Fail	Cum. Fail%	168hrs	300hrs
45	0	0.0%	0	0

E. High Temperature Storage Life (HTSL)

The purpose of this test is to expose time/temperature failure mechanisms and to evaluate long-term strong stability.
Conditions: JESD22-A103, JIS C 7021 B-10
T_A=T_{stg}(max)

Sample Size	#of Fail	Cum. Fail%	168hrs	300hrs
45	0	0.0%	0	0

F. Temperature Cycle Air-to Air (TMCL)

The purpose of this test is to evaluate the ability of the device to withstand both exposure to extreme temperature and the transition between temperature extreme, and to exposure excessive thermal mismatch between materials.
Conditions: JESD22-A104, JIS C 7021 A-4
Air to air, −65℃~150℃, 15 minutes dwell time at each temperature

Sample Size	#of Fail	Cum. Fail%	100cycles	200cycles
45	0	0.0%	0	0

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